

MS RCE  
PATENT  
8074-1143

**IN THE U.S. PATENT AND TRADEMARK OFFICE**

In re application of

Koichi NANIWAE

Conf. 9283

Application No. 10/573,492

Group 2892

Filed May 15, 2006

Examiner E. Jones

METHOD OF CLEANING TREATMENT AND METHOD FOR MANUFACTURING  
SEMICONDUCTOR DEVICE

**AMENDMENT TO ACCOMPANY A REQUEST FOR CONTINUED EXAMINATION**

Assistant Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

July 1, 2009

Sir:

The following Amendment and Remarks are submitted in response to the final Office Action dated April 1, 2009, together with a Request for Continued Examination (RCE) together filed concurrently herewith.

**Amendments to the Claims** are reflected in the listing of claims, which begins on page 2 of this paper.

**Remarks** begin on page 12 of this paper.